



Substitute for form 1449A/PTO

**INFORMATION DISCLOSURE
STATEMENT BY APPLICANT**

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Complete if Known

Application Number	10/789,042
Filing Date	February 27, 2004
First Named Inventor	Kie Y. Ahn
Group Art Unit	2815
Examiner Name	Matthew Landau

Sheet 1 of 3

Attorney Docket No: 1303.050US2

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EXAMINER

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Sheet 2 of 3

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